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Narrowband photoluminescence of Tin-Vacancy colour centres in Sn-doped chemical vapour deposition diamond microcrystals

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Tin-Vacancy (Sn-V) colour centres in diamond have a spin coherence time in the millisecond range at temperatures of 2 K, so they are promising to be used in diamond-based quantum optical devices. However, the incorporation of large Sn atoms into a dense diamond lattice is a non-trivial problem. The objective of our work is to use microwave plasma-assisted chemical vapour deposition (CVD) to grow Sn-doped diamond with submicron SnO₂ particles as a solid-state source of impurity. Well-faceted diamond microcrystals with sizes of a few micrometres were formed on AlN substrates. The photoluminescence (PL) signal with zero-phonon line (ZPL) peak for Sn-V centre at ≈ 620 nm was measured at room temperature (RT) and at 7 K. The peak width (full width at half-maximum) was measured to be 1.1–1.7 nm at RT and ≈ 0.05 nm at 7 K. The observed variations of ZPL shape and position, in particular, narrowing of PL peak at RT and formation of single-line fine structure at low- T , are attributed to strain in the crystallites. The diamond doping with Sn via CVD process offers a new route to form Sn-V colour centre in the bulk of the diamond crystallites.

This article is part of the Theo Murphy meeting issue 'Diamond for quantum applications'.

1. Introduction

Group-IV colour centres in diamond like Silicon-Vacancy (Si-V), Germanium-Vacancy (Ge-V) and Tin-Vacancy (Sn-V) possess narrowband photoluminescence (PL) emission at room temperature (RT) in the visible or near-IR spectral ranges and, thus, attract significant attention due to their possible applications in quantum information technologies [1–6], biomedicine (optical biomarkers and drug carriers) [7–9] and local optical thermometry [10–13]. Regarding quantum information applications, Sn-V is predicted to be the most suitable out of the listed Group-IV colour centres. The larger atomic radii of Sn leads to higher splitting in ground state and therefore spin-level structure can be resolved at higher temperature (approx. 2 K) with spin coherence time in the millisecond range [1,14]. This is less expensive in comparison with Si-V and Ge-V centres, which require sub-Kelvin regimes of operation [15]. Operating in a 2–5 K temperature range leads to a significant decrease in spin coherence times down to sub-microsecond in the case of Si-V and Ge-V [16,17]. Thus, reliable methods for the controlled formation of Sn-V centres in diamond are required.

The most prevalent of all Group-IV centres, the Si-V centre was known since the dawn of the era of lab-grown diamond in the early 1980s [18]. However, similar in structure Ge-V and Sn-V centres were both discovered less than a decade ago [15,19–23]. One of the reasons is the big size of germanium and tin atoms, which makes it a lot more difficult to be incorporated into the dense diamond lattice. The second obstacle is the Ge-C and Sn-C bonds, which are much weaker than C-C bonds, thus inhibiting the process of diamond doping [22]. Therefore, the first samples with Ge-V and Sn-V centres in diamond were obtained by using ion implantation [15,19]. Using ion implantation, the desired concentrations of the selected dopant along with the choice of the isotope content of the impurity is possible. The major downsides of the ion implantation are (i) collateral lattice damage [24] that is not fully compensated even after vacuum and high-pressure high-temperature (HPHT) annealing; (ii) the limitation on the implantation depth, so only the near-surface layer can be doped; and (iii) the lack of possibility to form bulk material with a universal distribution of impurity. In addition, for diamond, the excess concentration of the implanted ions may lead to the graphitization of the substrate [25].

Alternatively, Ge-doped diamond may be obtained using HPHT synthesis or chemical vapour deposition (CVD) [21,23,26,27]. However, the incorporation of Sn atoms into diamond is a non-trivial problem. The Sn-doped HPHT diamonds are limited in size to submillimetre crystals [22,28]. On the other hand, the CVD method, used for doping with Si and Ge, is still undeveloped for Sn doping. In the past, Sn-doped submicron crystals and epitaxial film were grown in microwave plasma using a mixture of SnO₂ and SnCl₂ particles as dopant source [29]. To the best of our knowledge that is the only experiment in the literature; however, the low spectral

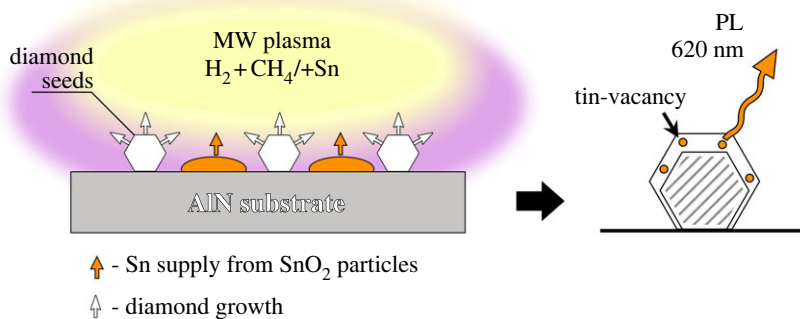


Figure 1. Scheme of the experiment.

quality of the resulting material made it unsuitable for quantum applications. Consequently, the current-state-of-the-art for using Sn-V centres for quantum applications is heavily dependent on implanted material [14,30–33].

In this work, we report on the formation of Sn-V centres in the CVD-grown high-quality diamond by using tin oxide nanoparticles as a solid-state source of impurity. The grown microcrystals exhibit narrowband luminescence with zero-phonon line (ZPL) near 620 nm, which is attributed to the emission of the formed Sn-V centres. The statistical characterization of the stress and luminescent characteristics (both at RT and at 7 K) of different microcrystals is performed.

2. Methods

The schematic of the experimental growth method is shown in figure 1. The Sn-doped diamond layers are deposited using MW CVD in methane–hydrogen gas mixtures. During the growth process, solid-state Sn-containing particles are placed near the diamond seeds to serve as the source of impurity during growth. Throughout the process, Sn atoms which are etched by atomic hydrogen, are incorporated into the diamond lattice, forming luminescent Sn-V centres.

The polycrystalline polished AlN plates with sizes of $10 \times 10 \times 1 \text{ mm}^3$ were chosen as substrates in order to avoid any interference from self-doping from the substrate material (for example, Si in the case of silicon substrates) [27,34]. Prior to deposition, the substrates were sequentially seeded in water-based slurries: first, with SnO_2 nanoparticles (size 90–300 nm, 10 mg ml^{-1}), and then with submicrometre HPHT diamond particles (size 250–500 nm, SYNDIA VANMOPES, SYP series, 0.3 mg ml^{-1}).

The diamond layers were deposited using ARDIS-100 (2.45 GHz, Optosystems Ltd, Russia) [35,36] CVD system with the following process parameters: the total gas flow of 500 sccm, the methane concentration of 4%, the gas pressure of 75 Torr and the microwave power 4.5 kW. The substrate temperature was kept at 980°C as measured with the two-colour pyrometer METIS M322 (SensorTherm GmbH). The deposition time was 20 min.

The process of Sn incorporation in diamond is thought to follow a mechanism similar to incorporation of Si and Ge atoms in diamond from respective solid precursor [20,34,37]. First, the Si (Ge) crystal is etched by atomic hydrogen to form volatile SiH_x (or GeH_x) products, which admix with CH_4 – H_2 plasma, then are adsorbed on the diamond surface, and eventually incorporated in the diamond lattice occupying an interstitial position. Following a similar pathway, the reaction chain for SnO_2 etching can be described as SnO_2 (solid) \rightarrow SnO \rightarrow Sn \rightarrow SnH_x (gas). The melting point (T_m) of SnO_2 is 1630°C and that of SnO and Sn are 1040°C and 231.9°C , respectively, which is lower than the melting point of the starting material.

For selective removal of the remaining Sn-containing particles, the as-grown samples were treated in a mixture of concentrated acids, $HF:HNO_3$ (1:1, 99% pure, 1 min). The surface

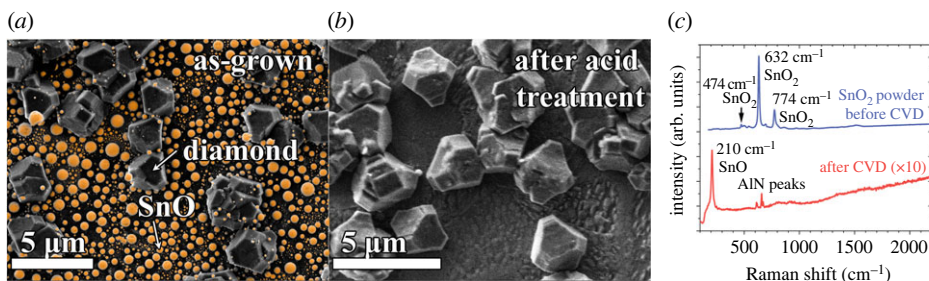


Figure 2. SEM images of the as-grown diamond microparticles on AlN substrates before (a) and after (b) acid treatment performed to remove Sn-containing particles (small ball-shaped particles coloured orange). (c) Raman spectra of Sn-containing particles before and after CVD growth.

morphology of the samples and crystal sizes were examined using a Tescan MIRA3 scanning electron microscope (SEM), equipped with an energy-dispersive X-ray spectroscopy (EDX) module for elemental analysis. Raman and PL spectra at RT were taken with a LabRam HR840 (Horiba) spectrometer in a confocal configuration. The laser beam of 473 nm wavelength was focused to a $\approx 1 \mu\text{m}$ spot on the sample surface on different locations (Olympus BX41).

For low-temperature measurements, PL spectra were measured with a custom-built fluorescence microscope. In brief, continuous-wave tuneable laser OPO C-Wave (Hubner Photonics) was used as an excitation source. However, in the spectral region near ZPL of Sn-V centres ($\approx 620 \text{ nm}$), the laser's wavelength could not be tuned continuously, which prevented us from the reliable investigation of photoluminescence excitation (PLE) spectra. Thus, the laser wavelength was set to the most effective excitation region from the a_{2u} state in the valence band [31] and in most experiments was 543 nm. The sample was placed in a closed-cycle He⁴ cryocooler CS204SF-DMX-20 (ARS). The temperature was controlled by Lakeshore 335. Emission from single microcrystal was collected with 50X Mitutoyo Plan Apo SL objective (NA = 0.42) and spectrally analysed with SOL Instruments spectrometer MS5204i equipped with a cooled CCD camera (QE > 90% near 620 nm). The spectral resolution was 0.033 nm for the investigated spectral region.

3. Results

(a) Synthesis and structure of Sn-doped diamond microcrystals

The SEM images of the surface of the as-grown sample are shown in figure 2. After the growth, diamond seeds evolved in a set of individual well-faceted microcrystals with sizes in the range of 2–4 μm and the shape typical for high-quality non-twinned diamond [38]. Near the crystals, plenty of submicron spherical-shaped Sn-containing particles were also found (figure 2a—coloured in orange using the method described in [39]). The Sn-based particles are sprinkled mostly between the diamond crystallites. Some smaller metal-based particles can be seen sitting on diamond facets, which can be ascribed to redeposition of the Sn compound. Those Sn-containing particles can be selectively removed by acid treatment (figure 2b). The comparison of the Raman spectra of the SnO₂ particles and the resulting Sn-containing diamond particles after the CVD process is shown in figure 2c. The powder SnO₂ spectrum shows a set of typical SnO₂ peaks at 474, 632 and 774 cm⁻¹ [40]. The spectrum of the particles after the CVD process did not have any of the SnO₂ peaks. However, a new peak appears at 210 cm⁻¹, which is the A_{1g} mode of suboxide SnO [41], indicating a reduction of tin(IV) oxide to tin(II) oxide in the plasma environment with atomic hydrogen abundance. The fact that we still observe tin-containing particles after 20 min of the CVD process is evidence of the absence of the intensive sublimation or plasma-chemical reaction. This opens up the possibility to use SnO₂ particles as the solid-state dopant source for prolonged diamond growth runs.

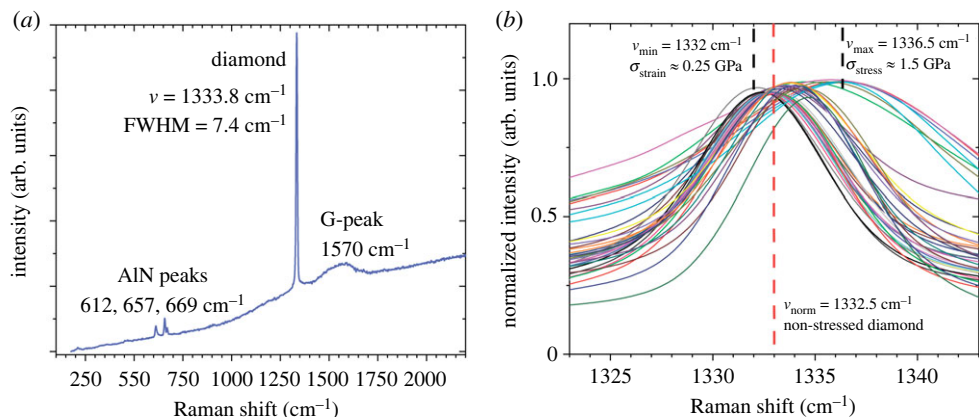


Figure 3. Raman spectra of the as-grown diamond microcrystal (a) and the combined normalized statistics of the Raman lines of the diamond phase over 40 investigated microcrystals (b).

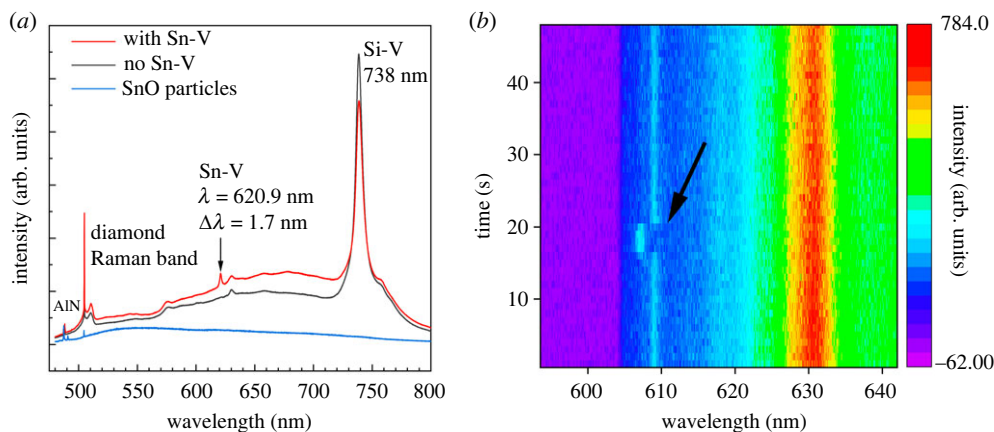


Figure 4. (a) PL spectra at room temperature of the as-grown: diamond microcrystals with Sn-V centres (top red curve); diamond microcrystals without Sn-V peaks (black curve), and remaining SnO particles (bottom blue curve). (b) Fluorescent track of one of the microcrystals showing pronounced spectral jump.

(b) Raman and photoluminescence spectra at room temperature

The phase composition of the diamond crystallites after acid treatment was studied at RT using Raman spectroscopy (figure 3). The spectra reveal the following features common for CVD-grown diamond: the narrow peak of the diamond phase near 1334 cm^{-1} , and the G-peak at 1570 cm^{-1} from graphitic carbon [42]. The set of peaks at $612, 657$ and 669 cm^{-1} are attributed to the AlN substrate [43].

The stress in diamond can be estimated from the shift of the Raman peak ($\Delta\nu = \nu - \nu_0$) from its ideal position at $\nu_0 = 1332.5 \text{ cm}^{-1}$ as $\sigma \text{ (GPa)} = -0.49 \cdot \Delta\nu \text{ (cm}^{-1}\text{)}$ [44,45]. Figure 3b shows the statistical data for the diamond Raman peak over 40 different diamond microcrystals. For different crystals, the position of the diamond peak lies in the range $1332.0\text{--}1336.5 \text{ cm}^{-1}$, while full width at half-maximum (FWHM) in the range of $6\text{--}10 \text{ cm}^{-1}$. The amount of stress in different microcrystals is roughly estimated to vary from $+0.25 \text{ GPa}$ tensile stress to -1.5 GPa compressive stress.

The PL spectra taken at RT at different locations of a selected sample are shown in figure 4. The remaining SnO particles do not give any contribution to the PL spectra other than Raman peaks in the $490\text{--}520 \text{ nm}$ region (blue curve). The most intense line in the PL spectra for all microcrystals

was the Si-V peak with ZPL at 738 nm and FWHM of ≈ 5 nm. Neither the position nor the width of the Si-V peak showed any unusual behaviour from crystal to crystal. On the other hand, the statistical investigation of the grown material shows that only a small portion of microcrystals, estimated at ≈ 10 – 15% of the total number, reveals any Sn-V signal observed as a clear PL peak near 620 nm (red curve in figure 4a). Most of the microcrystals do not show any signs of Sn-V (black curve in figure 4a). The FWHM of the observed Sn-V peaks ranged from 1.1 to 1.7 nm. This is much lower than typical values (approx. 5 nm) for Group-IV centres at RT even in low-stress high-quality single diamond crystals [15,19,21,26,46]. Additionally, this is close to the best value of 1.98 nm obtained in the work [31] for single-crystal diamond sample after Sn ion implantation and low-temperature vacuum annealing at 1200°C.

Another intriguing result is associated with spectral diffusion (figure 4b). We observed an example of reversible spectral jumps from 609.1 nm to 607.2 nm of a narrow PL peak (FWHM of ≈ 1 nm) in one of the microcrystals. We assume that the line can be attributed to the emission of the Sn-V centre even though the wavelength is sufficiently shifted. Spectral diffusion itself proves that the observed line originates from a single emitter because a correlated spectral jump for an ensemble of emitters is highly unlikely. The close location for the emitter to the surface may be the reason of spectral diffusion and possibly the shift of ZPL. The analysis of the second-order cross-correlation function is commonly used to unambiguously verify if the observed PL originates from a single emitter. However, it was not applicable here (at RTs) due to significantly high background fluorescent signal from the diamond particles in relation to the Sn-V emission (see figure 4a). Indeed, large contribution of noise signal to single-photon emitter luminescence can mask expected antibunching effect [47]. A reliable way to significantly improve the ‘signal-to-noise’ ratio is to perform measurements at low temperatures, in which case the single-photon emission prevails over the background luminescence noise, so an antibunching can be expected. However, our low-temperature experimental set-up was not equipped with Hanbury Brown and Twiss scheme and did not allow performing such measurements.

(c) Photoluminescence spectra of Sn-V centres at low temperatures

A series of the PL spectra for the several diamond microcrystals with Sn-V signal is shown in figure 5. Similar to the PL spectra investigation at RT, the low-T (7 K) measurements confirmed the absence of Sn-V signal from the majority of the microcrystals. The peak position for the Sn-V centre varied from crystal to crystal and was measured between ≈ 605 and ≈ 630 nm, while its FWHM (≈ 0.05 nm or ≈ 40 GHz) was relatively constant for the different crystals (figure 5a). The measured linewidths were comparable with the resolution of the spectrometer (approx. 0.033 nm), hence we provide values of FWHM after deconvolution [48]. In addition, some crystals had multiple lines near 620 nm (figure 5b), such spectra are rather typical for the diamond implanted with Sn ions but before/without additional HPHT annealing. This effect is attributed to inhomogeneous broadening (e.g. [31,49]). Similar spectra with single or multiple narrow lines were observed for CVD diamond films with Ge-V centres reported elsewhere [50].

4. Discussion

The results in this work clearly highlight the difficulty of incorporation of large atoms like Sn into dense diamond lattice. Despite the abundance of the Sn impurity sources near the growing diamond crystallites, the PL signal from Sn-V centres may be found only in a relatively small number of them. On the other hand, the unintentional Si doping, which had no active sources of impurity other than contamination on the reactor walls, resulted in an intense Si-V peak in PL spectra, that was registered for every diamond crystallite and was an order of magnitude more intense than any registered Sn-V peak near 620 nm. Considering the spectral diffusion that was registered for one of the Sn-V peaks, we attribute the obtained spectra with one narrow line to single Sn-V emitters (figure 5a). Spectra with multiple shifted peaks may be crystallites with multiple Sn-V centres (rather than one emitter with two- or four-line fine structure), as both the

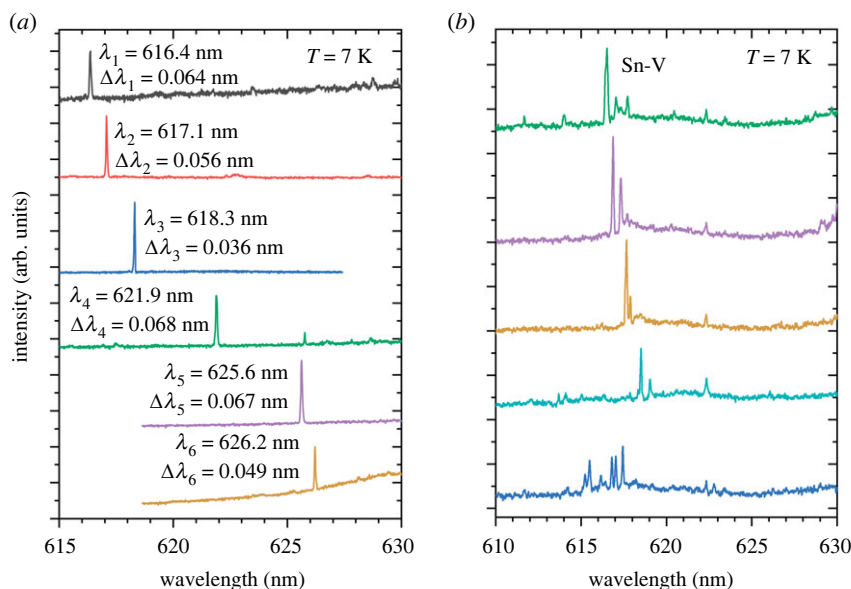


Figure 5. PL spectra of the selected diamond microcrystals: (a) a set of spectra with individual Sn-V peaks and (b) a set of spectra with multiple Sn-V peaks.

distance and intensity ratio between those peaks are inconsistent and rather random. However, in view of these results, three particular observations need to be addressed: (i) the random shifting of the Sn-V peak position; (ii) the single-line fine structure of the peak at low temperatures; and (iii) the unusually small width of the peak at RT.

(a) Sn-V peak shifts

For Group-IV colour centres in diamond, specifically for well-investigated Si-V and Ge-V, typical four-line fine structure of ZPL can be resolved at low temperatures [21,23,51,52]. A similar picture is observed for Sn-V centres, but a bigger split of the ground state leads to a lower Boltzmann population of the upper level of excited state, and therefore ZPL quartet reduces to a doublet at liquid-helium temperatures [15,22,28]. However, the exact fine structure for Sn-V centres at low temperatures does not necessarily show a two-level structure and varies in the literature [15,22,31,53]. In the case of monocrystals, the majority of defects that induce internal stress are ‘healed’ either during the HPHT process itself or by additional annealing. The shift of the Sn-V peak position in our samples may be explained by the random stress in the environment of the centre. It was shown before that the PL peaks of Group-IV centres shift under high-pressure conditions. The exact shift values for Ge-V and Sn-V centres are an order-of-magnitude higher than that for Si-V centres [54]. So, although for Si-V centres this effect may be neglected, for Ge-V centres such a random shift in the peak position has already been reported [55]. The observed values of tensile/compressive stress of $+0.25$ to -1.5 GPa imply that the possible spectral shift may reach up to $\approx 10\text{ nm}$. Another factor that could potentially influence the position of the Sn-V peak is the isotopic shift [56], however, in the case of Sn isotopes the shift values are expected to be much smaller than for Si and Ge [53].

(b) Single-line fine structure

As it was mentioned before, the typical fine structure of any Group-IV centre at low temperatures usually consists of four narrow lines, which represent four possible transitions between two split

ground states and two split excited states [51]. Such shape of the spectrum, however, normally is characteristic for the most high-quality and stress-free single crystals [46,56]. The excessive number of defects together with the high values of the stress in the film leads to the merging of those four lines to a single broad peak (see [26]). For Si-V centres, an increase in stress leads to a change in the relative intensity and position of those four components. First demonstration of this effect was done in a dissertation by Hepp [57] (see fig. 5.2 on p. 164), where it was shown that the compressive stress applied to Si-doped diamond (less than 0.4 GPa) changes the four-line fine structure of Si-V centres. Similar results were obtained in the work by Meesala *et al.* [58], where stress was deliberately and controllably applied to Si-V centres in order to affect the spectrum at low temperatures. In both works, it was shown that if sufficient stress is applied to the Si-V centre, the one-line fine structure can be obtained, with the other three lines being weak and distanced from the main line. Moreover, according to works [53,54], the PL behaviour of Sn-V centres is even more sensitive to stress, so a single-line thin structure is well-expected even for relatively low values of stress revealed for diamond microcrystals in the current study.

For some crystals, we also observed the PL spectra with multiple narrowband lines (figure 5b). This type of spectra was reported by Iwasaki *et al.* [15] to be characteristic of Sn-V centre ensemble at low temperatures if HPHT annealing is not performed in Sn-implanted high-quality single-crystal diamond. Thus, in our study, the multiple narrow line structure may be attributed to a small ensemble of randomly shifted narrowband Sn-V centres in one diamond crystallite. We see that stresses are inhomogeneous within one crystallite, and the variation of stresses inside one crystal may be even bigger than the variation between different crystals (FWHM of the Raman line is much bigger than shifts between various crystals).

(c) The linewidth of Sn-V at room temperature

The observation of narrowband (FWHM 1.1–1.7 nm) luminescence and spectral diffusion at RTs are the most interesting and unexpected findings of this work. Slightly larger values for $\text{FWHM}(\text{Sn-V}) = 1.98 \text{ nm}$ were reported by Görlitz *et al.* [31] for the diamond single-crystal implanted with Sn ions followed by vacuum annealing at 1200°C. Interestingly, the sample annealed under HPHT conditions (thus, less defective and with smaller values of residual stress) had a much broader PL peak with $\text{FWHM}(\text{Sn-V}) = 6.15 \text{ nm}$ at RT, while still demonstrating a two-line fine structure at $T = 10 \text{ K}$. Moreover, the low-temperature PL spectrum of the vacuum-annealed sample (fig. 7b in [31]) is rather similar to the spectra shown in figure 5b with a set of narrow Sn-V peaks. The observed peaks showed a random distribution of their intensities and positions. The high concentration of Sn-V centres made it difficult to observe separate Sn-V lines from single centres in [31]. However, combined with our results, we hypothesize that Sn-V centres in a diamond under stress experience a sufficient shift in the typical four-level energy structure of Group-IV colour centres. This results in the change of its PL behaviour both at low and RT. The variations in Sn-V peak shift and broadening may be influenced not only by the absolute values of the strain but also by variation of ratio between longitudinal strain and transverse strain [59] even if the strain magnitude is constant. Recently, Meesala *et al.* [58] demonstrated the control over the electronic structure of Si-V centres with stress/strain by using a laboratory-built nano-electro-mechanical system. Following their logic, we suggest that the control over strain/stress of diamond with Group-IV centres can be efficiently used to fine-tune diamond-based quantum devices and also to control the luminescent properties of diamond in general.

5. Conclusion

In this work, we presented the fabrication of a luminescent Sn-doped diamond using microwave plasma-assisted CVD in methane–hydrogen gas mixtures. The SnO_2 nanoparticles, which were heated and etched by the plasma, were used as solid-state impurity source. The obtained diamond microcrystals with sizes of 2–4 μm exhibit the PL of Sn-V colour centres near 620 nm. At RT, the measured PL peak position was 620.9 nm, while FWHM was as small as 1.1–1.7 nm. At low

temperatures (7 K), the FWHM of the Sn-V ZPL decreased to ≈ 0.05 nm (≈ 40 GHz), while the peak position was randomly shifted. The shift in the peak position is attributed to the random values of stress/strain in different diamond crystals.

The obtained results open the path to formation of luminescent Sn-doped CVD diamond with the potential to improve the characteristics of the resulting material by additional irradiation and/or HPHT annealing. In addition, the narrowing of the Sn-V ZPL, both at low and RTs stimulates a further investigation of the controllably strained/stressed diamond with Group-IV colour centres for a multitude of applications in quantum optics.

Data accessibility. The Raman and PL spectra supporting this article have been uploaded as part of the electronic supplementary material [60].

Declaration of AI use. We have not used AI-assisted technologies in creating this article.

Authors' contributions. V.S.: conceptualization, funding acquisition, project administration, resources, visualization, writing—original draft, writing—review and editing; A.M.: data curation, investigation; A.N.: data curation, investigation, writing—original draft; I.T.: investigation; S.S.: investigation, software, visualization; I.E.: data curation, formal analysis, investigation, writing—original draft; M.E.: investigation; M.P.: investigation; S.M.: formal analysis, validation, writing—original draft, writing—review and editing; V.R.: supervision, writing—original draft, writing—review and editing; A.N.: formal analysis, supervision, validation, writing—original draft, writing—review and editing.

All authors gave final approval for publication and agreed to be held accountable for the work performed therein.

Conflict of interest declaration. We declare we have no competing interests.

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